

PAIDC

QUERY CONTROL FORM		RTIS USE ONLY	
Application No. <u>101054,911</u>	Prepared by <u>N.H.</u>	Tracking Number <u>05884460</u>	
Examiner-GAU <u>Kim-2874</u>	Date <u>1-29-04</u>	Week Date <u>01/05/04</u>	
	No. of queries <u>1</u>	<u>IFW</u>	

JACKET

a. Serial No.	f. Foreign Priority	k. Print Claim(s)	p. <u>PTO-1449</u>
b. Applicant(s)	g. Disclaimer	l. Print Fig.	q. PTOL-85b
c. Continuing Data	h. Microfiche Appendix	m. Searched Column	r. Abstract
d. PCT	i. Title	n. PTO-270/328	s. Sheets/Figs
e. Domestic Priority	j. Claims Allowed	o. PTO-892	t. Other

SPECIFICATION

- a. Page Missing
- b. Text Continuity
- c. Holes through Data
- d. Other Missing Text
- e. Illegible Text
- f. Duplicate Text
- g. Brief Description
- h. Sequence Listing
- i. Appendix
- j. Amendments
- k. Other

CLAIMS

- a. Claim(s) Missing
- b. Improper Dependency
- c. Duplicate Numbers
- d. Incorrect Numbering
- e. Index Disagrees
- f. Punctuation
- g. Amendments
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- i. Missing Text
- j. Duplicate Text
- k. Other

MESSAGE

PTO-1449: Please either initial or line through Citations. Copy provided for reference.

Thank you

initials N.H.

RESPONSE

initials

INFORMATION DISCLOSURE CITATION
(Use several sheets if necessary)

APR 29 2002

Docket Number (Optional)
12591-US

Application Number
10/054,911

Applicant(s)
Siegfried Janz et al.

Filing Date
01/25/02

Group Art Unit
2874

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		5,937,113	08/10/99	He et al.	385	11	04/17/98

FOREIGN PATENT DOCUMENTS

REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

		"Design, Tolerance Analysis, and Fabrication of Silicon Oxynitride Based Planar Optical Waveguides for Communication Devices", Kerstin Worhoff et al., Journal of Lightwave Technology, Vol. 17, No. 8, August 1999, pages 1401-1407.

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.